

Supporting Information

Reflectin 1A [Euprymna scolopes] AAQ21389:

MNRFMNRYRPFNNMYSNMYRGRYRGMM**EPMSRMTMDFQGRYMDSQGRM**VDPRIYDYYGRFNDYD
RYYGRSMFNYGWMMMDGDRYNRYNRW**MDYPERYMDMSGYQMDMSGRWMDMQGRH**CNPYSQWMM
YNYNRHGYYPNYSYGRHMFYPERW**MDMSNYSMDMYGRYMDRWGRY**CNPFSSQYMNYYGRYWNYPGYN
NYYYSRNMYPERY**FDMSNWQMDMQGRWMDNQGRY**CSPYWNNWYGRHMYYPYQNNYFYGRYDYPG
MDYSNYQMDMQGRYMDQYGMNDYYY

Reflectin 2A [Euprymna scolopes] AAQ21392:

MNRYMTRFRNFYGNMYRGRYRGMM**EPMSRMTMDFQGRYMDSQGRM**VDPRIYDYYGRYNDYDRYYGRS
MFNYGWMMMDGDRYNRYNRW**MDFPERYMDMSGYQMDMYGRWMDMQGRH**CNPYSQMMYNYNRHG
YYPNYSYGRHMFYPERW**MDMSNYSMDMYGRYMDRWGRY**CNPFYQFYNHWNRYGNYPGYNNYYMYYP
ERY**FDMSNWQMDMQGRWMDMQGRY**CSPYWYNWYGRHMYYPYQNYWYGRYDYPG**MDYSNWQMD**
MQGRWMDMQGRYMDYPYNYNWY

Sequence 46 (reflectin 2D) [Euprymna Scolopes] US 7314735 ABZ24324:

MNRYMNRFRNFYGNMYRGRYRGMM**EPMSRMTMDFQGRYMDSQGRM**VDPRIYDYYGRFNDYDRYYGR
SMFNYGWMMMDGDRYNRYNRW**MDFPERYMDMSGYQMDMYGRWMDMQGRH**CNPYSQWMMYNYN
RHGYYPNYSYGRHMFYPERW**MDMSNYSMDMYGRYMDRWGRY**CNPFYQFYNHWNRYGNYPGYSSYYM
YPERY**FDMSNWQMDMQGRWMDMQGRY**CSPYWYNWYGRHMYYPYQNYWYGRYDYPG**MDYSNWQ**
MDMQGRWMDMQGRYMDYPYNYNWNH

Reflectin 1 [Sepia officinalis] CCG28037:

MNRYMMRNRPMYGNMYRTGKKYRGV**MEPMSRMTMDFQGRYMDSQGRM**VDPRIYDYYGRWNDYDR
YYGRSMFNYPHMDGHQHGGW**MDFPERWMDMSNYQMDMQGRWMDMQGRH**CQPFNQWGYNRH
GNYPSSYYGRN**MFYPERWMDMSNWQMDTQGRWMDMQGRY**GSPFNQWGYNRHGYYPGSSYGRNMY
H**PERWMDMSNYQMDMQGRWMDMHGRH**VNPFSSHSMHGRNWSYPYNYSSRH**MDYPERNMDMSN**
WQMDMQGRWMDMQGRHMDPSWSNMHDNHNYWF

Reflectin A2 [Doryteuthis opalescens] KF661516:

MNRYMMRHRPMSNMYRTGRKYRGV**MEPMSRMTMDFQGRYMDSQGRM**VDPRIYDYYGRCHDYDRYNG
RSMFNNGPYMDGQRYGGW**MDFPERYMDMSGYQMDMHGRWMDSQGRY**CNPMGHSWSNRQGYYPGS
NYGRNMFNPERY**MDMSGYQMDMQGRWMDMGGRH**VNPFSSHSMYGRNMFNPSYFSNRH**MDNPERYM**
DMSGYQMDMQGRWMDTQGRYMDPSMSNMYDNYNYWY

Figure S1 Name, origin, UniProt ID, and amino-acid sequence of all reflectin isoforms used in this study. Repeating motif regions are highlighted bold.

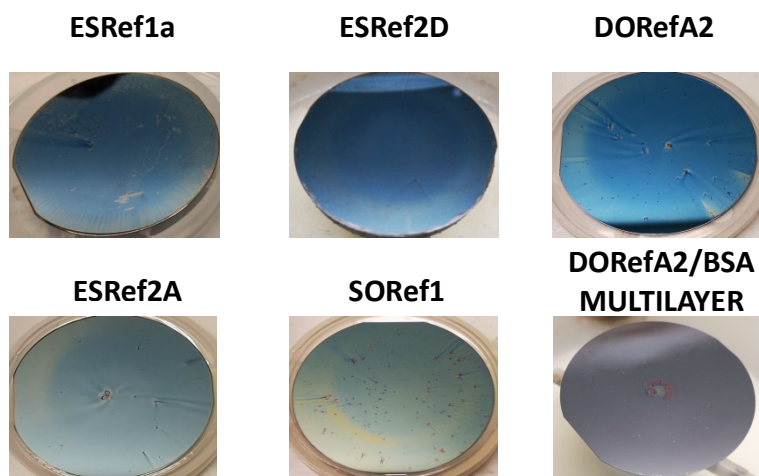


Figure S2 Optical images of reflectin thin-films following fabrication by spin coating 1% w/w reflectin in HFIP onto a clean Si wafer. Camera images were taken following drying. DORefA2/BSA multilayer films were fabricated by spin coating reflectin and BSA sequentially.

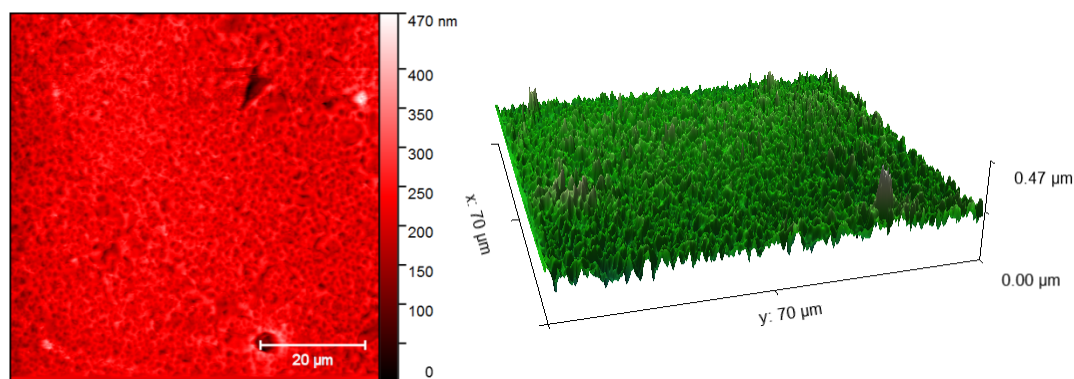


Figure S3 Representative atomic force microscopy (AFM) images of a DORefA2 thin-film fabricated by spin coating 1% w/w DORefA2 in HFIP onto a clean Si wafer. AFM data was processed using the Gwyddion software package, <http://gwyddion.net/>.

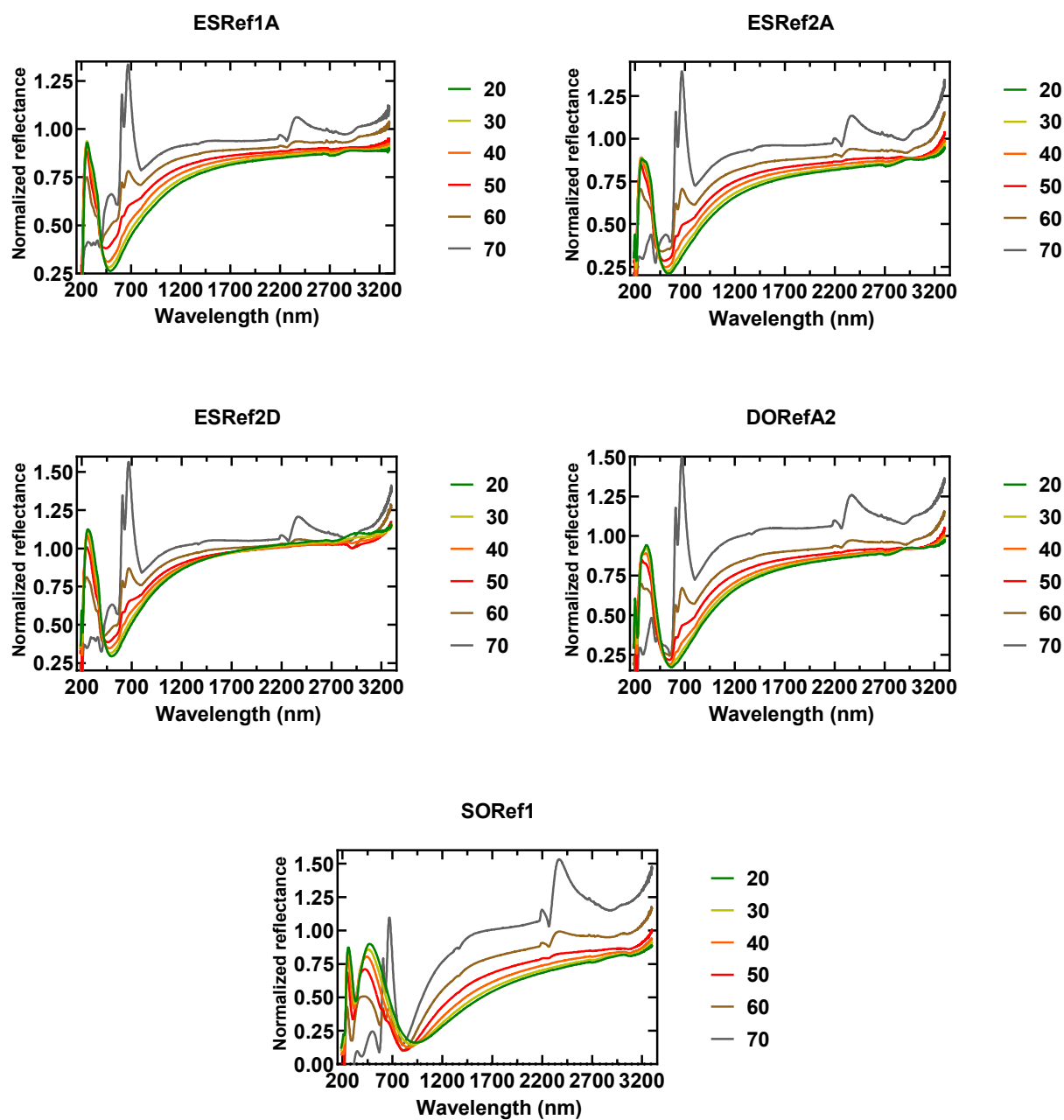


Figure S4 UV-Vis-NIR reflectance spectra (185-3300 nm) of reflectin-based single-layer films fabricated by spin coating 1% w/w reflectin in HFIP onto clean Si wafers. The angle of incidence was varied between 20-70 degrees (10 degree intervals).

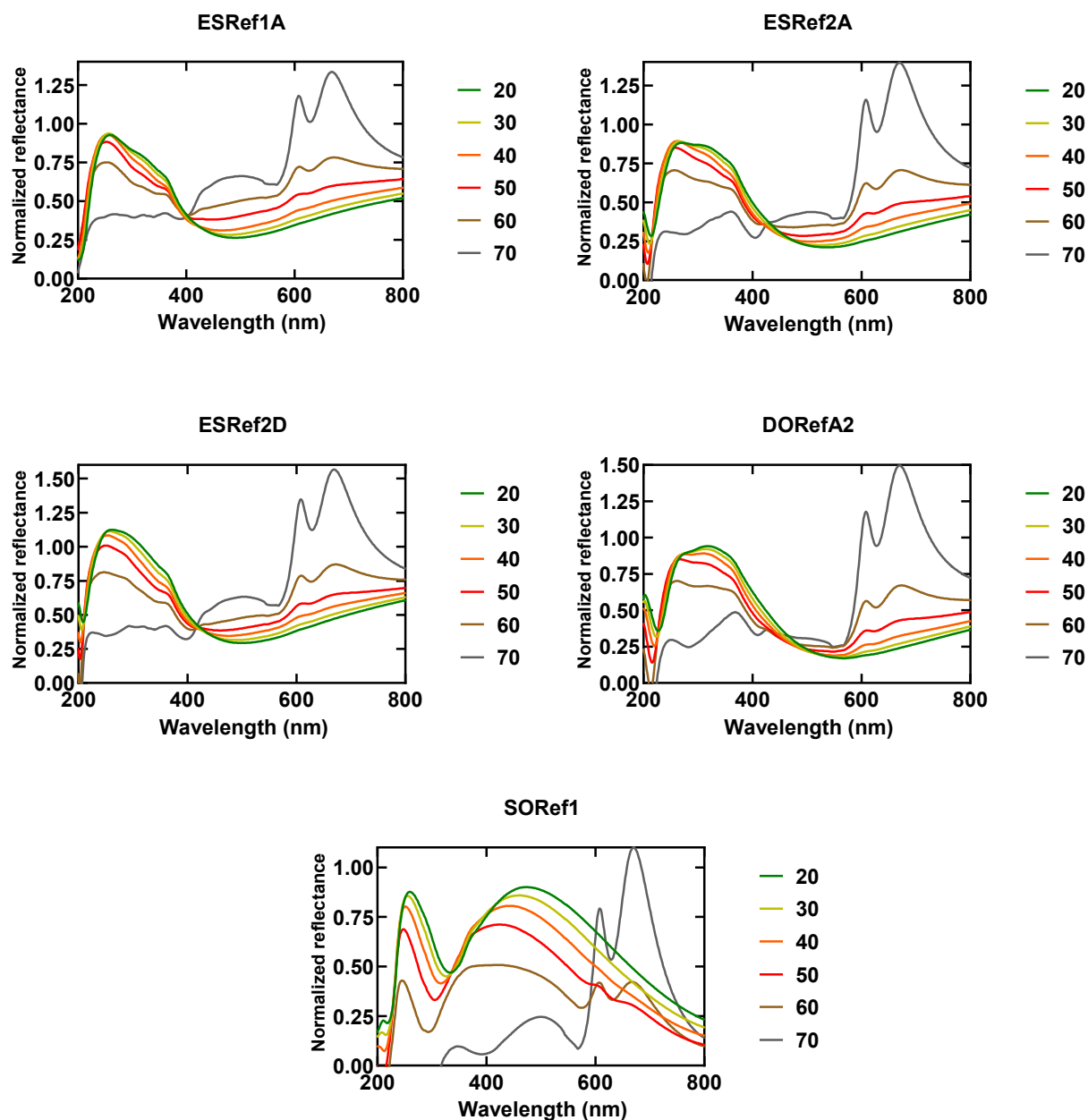


Figure S5 UV-Vis reflectance spectra (200-800 nm) of reflectin-based single-layer films fabricated by spin coating 1% w/w re flectin in HFIP onto clean Si wafers. The angle of incidence was varied between 20-70 degrees (10 degree intervals).

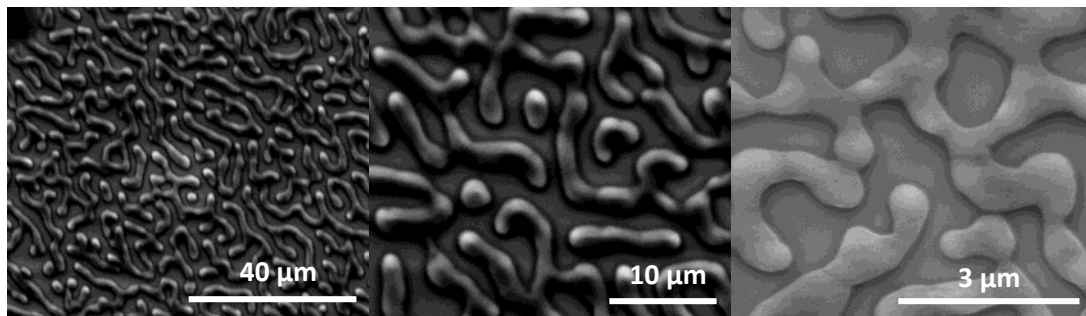


Figure S6 Representative SEM micrographs of the surface of a reflectin thin-film fabricated by sping coating 1% w/w reflectin in HFIP onto a clean Si wafer.

Agrobacterium fabrum PHY1:

MSSHTPKLDSCGAEPIHIPGAIQEHGALLVLSAREFSVVQASDNLANYIGVDLPIGAVATEA
 NLPFISVLSAWYSGEESNFRYAWAEKKLDVSAHRSGTLVILEVEKAGVGESAEKLMGELTS
 LAKYLNSAPSLEDALFRTAQLVSSISGHDRTLIYDFGLDWSGHVVAEAGSGALPSYLGLRF
 PAGDIPPQARQLYTINRLRMIPDVVDYKPVPIRPEVNAETGAVLDMFSFQLRSVSPVHLEYMR
 NMGTAASMSVSIVVNGALWGLIACHHATPHSVSLAVREACDFAAQLLSMRIAMEQSSQD
 ASRRVELGHIQARLLKGMAAAEKWVDGLLGGEREDLLKQVGADGAALVLGDDYELV
 GNTPSREQVEELILWGEREIADVAFATDNLAGNYPTAAAYASVASGIIAMRVSELHGSLI
 WFRPEVIKTVRWGGDPHKTQESGRIHPRKSFEIWKEQLRNTSFPWSEPELAAARELRGAI
 GIVLRKTEEMADLTRELQRTNKELEAFSFSVSHDLRAPFRHIVGFAQLLRERSDALDEKSL
 HYLQMISEAALGAGRLVDDLLNFSQLGRTQLTLKPVDMQKVVSEVRRSLSHAVSDRQIEW
 RIGALPVIFGDPTLLRQVWYNLIENAIKYSSREPVSIIITISAVETEDDVTYSVEDNGVGFDMA
 YYNKLFGVFQRLQRVEDFEGTGIGLALVRRIVERHHGLVGAEGTVGEGATFSFTLPVTKVE
 EEKIA

Figure S7 Amino acid sequence of phytochrome 1 from *Agrobacterium fabrum* used in this study.